

III-V Semiconductor Chemical Bench

Operating Procedures LINK



Equipment Description:

The chemical bench is equipped with two hotplates, two sinks, DI water sprayer and solution aspirator. There are programmable timers mounted on the control panel.

<i>Materials Allowed</i>	<i>Materials Not Allowed</i>
III-V compounds	Solvents
Acids	SU-8
Bases	
Glass	
Metals	
Oxidizers	
Photoresists	
Quartz	
Silicon	
Silicon dioxide	
Silicon nitride	